Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application:

Listing of Claims:

Claim 1 (Currently amended): A process for <u>synthesizing a</u> the asymmetric synthesis of the chiral compound of the structure comprising the steps of

where Y is H, mono or multisubsubstituted electronwithdrawing group or electrondonating group, wherein Y can be located at m,o,or p position of the benzene ring; P is hydgogen or an amino protecting group,

Rf is fluoro-containing alkyl,

R is trialkylsilyl, alkyl, cycloalkyl or aryl group,

 R^6 is hydrogen when R^5 is hydroxy, also R^6 and R^6 can be HNCO of the structure or its enantiomer

where Y. P. R. Rf is the same as above:

Comprising the steps of:

(a) providing a mixture of mixing a chiral ligand (1R, 2R)-2-N, N- substituted-1(substituted -phenyl)-2-R³-substituted-2-aminoethanol or its enantiomer having a formula of -of-the structure

$$Z \xrightarrow{\text{IV}} \begin{array}{c} OH \\ R^3 \\ NR^1R^2 \end{array} \text{ or } Z \xrightarrow{\text{IV}} \begin{array}{c} P^3 \\ NR^1R^2 \end{array}$$

wherein R^1 , R^2 is <u>an</u> amino protecting group; [.] and R^3 is <u>an</u> alkyl₃[:] alkyl₂ substituted with <u>an</u> alkyloxy or silyoxy, carboxylic group, carbalkoxy group, hydroxyl methyl, cycloalkyl, aryl, or CH_2OR^4 , wherein R^4 is <u>being</u> an oxygen protecting group[.]; Z is H, a mono_or multi_subsubstituted electron_withdrawing group or electron-donating group, <u>and wherein Z can be</u> located at m-,o-, or p-positon of the benzene ring; with a terminal alkyne and a Zn(II), Cu(II) or Cu(I) salt salts in the presence of an organic base in <u>an</u> aprotic solvent,

wherein the terminal alkyne is

R is a trialkylsilyl, alkyl, cycloalkyl, or aryl group the same as above,

 (b) mixing with the mixture with a of step-(a)-of reactant having a formula of the structure Appl. No. 10/551,770 Amendment dated September 14, 2007 Reply to Office Action of June 14, 2007

or of the structure

wherein P is hydrogen or an amino protecting group, Rf is a fluoro-containing alkyl, Y is

H, a mono- or multi-subsubstituted electron-withdrawing group or electron-donating
group and located at m-, o-, or p-position of the ring the same as above;

isolating and obtaining a chiral compound obtains the target addition product after

Claim 2 (Currently amended): The A process of claim 1, wherein the process is for the asymmetric synthesis of the chiral compound of the structure or its enantiomer

Comprising the steps of:

(a) providing a mixture of the chiral ligand (IR, 2R)-2-N, N- substituted-1(substituted -phenyl)-2-R³-substituted-2-aminoethanol or its enantiomer is (IR, 2R)-2-

N,N-substitutedamino-1-(substituted-phenyl)-2-substituted-2-aminoethanol having a formula of -of-the-structure, or-its enantiomer

with a terminal alkyne and a Zn(II) or Cu salts in the presence of an organic base in aprotic solvent, wherein the terminal alkyne is

(b) mixing with the mixture of step (a) of the reactant is of the structure

Claim 3 (Currently amended): The A process of claim 2, wherein the chiral ligand is (1R, 2R)-2-N,N-substitutedamino-1-(substituted-phenyl)-3-O-R⁴substituted-propane-1-ol or its enantiomer having a formula of of the structure

Claim 4 (Currently amended): The A process of claim 1, wherein the process is for the

asymmetric synthesis of the chiral compound of the structure or its enantiomer

Comprising the steps of:

(a) providing a mixture of the chiral ligand is (1R, 2R)-2-N, N-substituted mino-1-(substituted-phenyl)-2-R³-substituted-1-ethanol or its enantiomer having a formula of τ of the structure.

with a terminal alkyne and a Zn(II) or Cu salts in the presence of an organic base in aprotic solvent, wherein the terminal alkyne is

(b) mixing with the mixture of step (a) of and the reactant is of the structure

Claim 5 (Currently amended): The A process of claim 1, wherein R1 and R2 is an

alkyl, substituted alkyl, benzyl, trialkylsilyl, or substituted benzyl, the substituted group ean-be being a phenyl, naphenyl, halo, nitro, hydroxy, C_1 - C_3 hydroxyalkyl, C_1 - C_4 alkyl, or C_1 - C_3 alkoxy[;], or R^1 , R^2 being ean-be -(CH₂)_nX(CH₂)_m-, where X being ean-be CH₂, C_4 , or NH; n.m is an integer from 1 to 6[.];

P is hydrogen, <u>an</u> alkyl, substituted alkyl, benzyl, trialkylsilyl, or substituted benzyl, the substituted group ean-be being a phenyl, naphenyl, halo, nitro, hydroxy;

R⁴ is <u>an</u> alkyl, substituted alkyl, benzyl, trialkylsilyl, or substituted benzyl, the substituted group ean be being a phenyl, naphenyl, halo, nitro, hydroxy, C₁~C₃ hydroxyalkyl, C₁~C₄ alkyl, C₁~C₃ alkoxy or CN;

 $\underline{the} \ electron_withdrawing \ group \ is \ \underline{a} \ halogen, NO_2, CF_3, CH_3SO_2, CH_3CH_2SO_2 \ ,$ $PhCH_2OCO, \ or \ AcO[.];$

the electron-donating group is an alkoxy, OH, Me₂NCH₂CH₂O, Et₂NCH₂CH₂O, NH₂, or C1~C4 alkyl.

Claim 6 (Currently amended): The A process of claim 1, wherein R^1 and R^2 is \underline{a} $C_1 \sim C_{20}$ alkyl, $C_1 \sim C_{20}$ substituted alkyl, trialkylsilyl, benzyl, or substituted benzyl, the substituted group ean-be being \underline{a} phenyl, naphenyl, halo, nitro, hydroxy, $C_1 \sim C_3$ hydroxy alkyl, $C_1 \sim C_{20}$ alkyl, \underline{or} $C_1 \sim C_3$ alkoxy $\{:]_a$ or R^1 , R^2 ean-be being $\underline{-}$ (CH₂) \underline{ax} (CH₂) \underline{mx} , where X ean-be being CH₂, O or NH;

n,m is an integer from 1 to 6;

 $R^3 \text{ is } \underline{a} \ C_1 \sim C_{20} \text{ alkyl}[;]_* \ C_1 \sim C_{20} \text{ alkyl substituted with } \underline{an} \text{ alkyloxy or silyoxy,}$ carboxylic group, $C_1 \sim C_{20} \text{ carbalkoxy group, hydroxyl methyl, } C_3 \sim C_{20} \text{ cycloalkyl, aryl, or } carboxylic group, C_1 \sim C_{20} \text{ carbalkoxy group, hydroxyl methyl, } C_3 \sim C_{20} \text{ cycloalkyl, aryl, or } carboxylic group, C_1 \sim C_{20} \text{ carbalkoxy group, hydroxyl methyl, } C_3 \sim C_{20} \text{ cycloalkyl, aryl, or } carboxylic group, C_1 \sim C_{20} \text{ carbalkoxy group, hydroxyl methyl, } C_3 \sim C_{20} \text{ carbalkoxylic group, } carboxylic group, C_1 \sim C_{20} \text{ carbalkoxylic group, } carboxylic group, C_1 \sim C_{20} \text{ carbalkoxylic group, } carboxylic group, \\ carboxylic group, C_1 \sim C_{20} \text{ carbalkoxylic group, } carboxylic group, \\ carboxylic$

CH₂OR⁴, wherein R⁴ is <u>being a</u> C₁~C₂₀ alkyl, C₁~C₂₀ substituted alkyl, benzyl, or substituted benzyl, the substituted group ean-be <u>being a</u> phenyl, naphenyl, halo, nitro, hydroxy, C₁~C₃ hydroxyalkyl, C₁~C₄ alkyl, C₁~C₃ alkoxy, or CN;

Z is H, F, Cl, Br, I, CH₃SO₂, OH, PhCH₂O, AcO, MeO, EtO, Me₂NCH₂CH₂O, Et₃NCH₅CH₅O, PhCH₅OCO, t-Bu, t-Pr, NH₂, or NO₂;

 $\label{eq:problem} P \ is \ hydrogen, \ \underline{a} \ C_1 \sim C_{20} \ alkyl, \ C_1 \sim C_{20} \ substituted \ alkyl, \ benzyl, \ trialkylsilyl \ or substituted \ benzyl, the substituted \ group \ \underline{ean-be} \ \underline{being} \ \underline{a} \ phenyl, \ naphenyl, \ halo, \ nitro, \ hydroxy, \ C_1 \sim C_3 \ hydroxyalkyl, \ C_1 \sim C_4 \ alkyl, \ C_1 \sim C_3 \ alkoxy_4 \ or \ CN;$

Y is H, F, Cl, Br, I, CH₃SO₂, OH, PhCH₂O, AcO, MeO, EtO, Me₂NCH₂CH₂O, Et₂NCH₂CH₂O, PhCH₂OCO, *t*-Bu, *i*-Pr, NH₂, or NO₂;

Rf is a C₁~C₂₀ fluoro-containing alkyl;

R is a trialkylsilyl, C₁~C₂₀ alkyl[.], C₃~C₂₀ cycloalkyl, or aryl group[;].

Claim 7 (Currently amended): The A process of claim 1, wherein R^1 and R^2 is \underline{a} $C_1 \sim C_4$ alkyl, tri-phenylmethyl, t-butyldimethylsilyl, benzyl unsubstituted or substituted with $C_1 \sim C_4$ alkyl[:], para-methoxy benzyl[:], para-nitrobenzyl[:], para-chlorobenzyl[:], 2, 4-dichlorobenzyl[:], or 2, 4-dimethoxybenzyl[:], or R^1 , R^2 ean-be being $-(CH_2)_2O(CH_2)_2$, $-(CH_2)_2N(CH_2)_2$, $-(CH_2)_2$, $-(CH_2)_2$, $-(CH_2)_2$, $-(CH_2)_2$, $-(CH_2)_2$;

 R^3 is \underline{a} C_1 - C_4 alkyl, C_1 - C_4 alkyl substituted with alkyloxy or silyoxy, carboxylic group, C_1 - C_4 carbalkoxy group, hydroxyl methyl, C_3 - C_6 cycloalkyl, aryl or CH_2OR^4 , wherein R^4 being \underline{a} is C_1 - C_4 alkyl, tri-phenyl methyl, t-butyl- dimethylsilyl, benzyl unsubstituted or substituted with C_1 - C_4 alkyl, para-methoxy benzyl, para-nitrobenzyl,

para-chlorobenzyl, 2, 4-dichlorobenzyl, 2, 4- dimethoxybenzyl, or trialkylsilyl groups;

Z is H, F, Cl, Br, I, CH₃SO₂, OH, PhCH₂O, AcO, MeO, EtO, Me₂NCH₂CH₂O, EbNCH₂CH₃O, PhCH₃OCO, t-Bu, i-Pr, NH₃, or NO₂:

P is hydrogen, a $C_1 \sim C_4$ alkyl, tri-phenylmethyl, t-butyldi- methylsilyl, benzyl unsubstituted or substituted with $C_1 \sim C_4$ alkyl; para-methoxy benzyl, para-nitrobenzyl, para-chlorobenzyl, 2,4-dichlorobenzyl, para-chlorobenzyl, 2,4-dimethoxy- benzyl;

Y is H, Cl, Br, CH₃SO₂, CH₃CH₂SO₂, NO₂, or F;

Rf is a C₁~C₄ fluoro-containing alkyl;

R is <u>a C₁~C₄ alkyl, C₃~C₆ cycloalkyl, or aryl group, wherin aryl is being a phenyl, naphenyl, furan, thiophene, or pyrrole;</u>

Halogen halogen or halo is a fluoro, chloro, bromo, or and iodo.

Claim 8 (Currently amended): The A process of claim 1, wherein the stoichiometric ratios are about 0.1-3:0.1-3:1-4:1 of ligand: Zinc salt: the organic base: substrate ketone or ketimine.

Claim 9 (Currently amended): The A process of claim 1, wherein the Zine salt is selected from ZnCl₂, ZnBr₂, ZnF₂, ZnI₂, Zn(OTf)₂, CuCl₂, CuBr₂, Cu(OTf)₂, CuCl, CuBr, or Cu(OTf).

Claim 10 (Currently amended): The A process of claim 1, wherein the organic base is selected from MeN(iPr)₂, HNEt₂, N(iPr)₃, pyridine, NEt₃, piperidine, EtN(iPr)₂, or Bu;N.

Claim 11 (Currently amended): The A process of claim 1, wherein the reaction temperature is 0-100°C

Claim 12 (Currently amended): The A process of claim 11 4, wherein the reaction temperature is 0-50°C.

Claim 13 (Currently amended): The A process of claim 1, wherein the <u>aprotic reaction</u> solvent is selected from THF, dioxane, Et₂O, benzene, <u>a</u> mono or multi-alkylsubstituted-benzene, DME, toluene, n-hexane, CH₂Cl₂ and <u>a</u> cyclohexane, or <u>a</u> mixture thereof. One preferred solvent is toluene.

Claim 14 (Currently amended): The A process of claim 1, wherein further comprising the step of

quenching the <u>mixture</u> reaction by adding a proton source to give the <u>chiral</u> desired compound.

Claim 15 (Currently amended): The A process of claim 1, comprising the steps of wherein it is for the asymmetric synthesis of the chiral compound of the structure

or of the structure

Comprising the steps of:

(a) providing a mixture of mixing 0.1~3 molar equivalent of (1R,2R)-2-N,N-substitutedamino-1-(4-Z-substituted-phenyl)-3-O-R⁴-substituted propane-1-ol having a formula of [,] of the structure

with 0.1~3 molar equivalent of cyclopropylacetylene, and 0.1~3 molar equivalent of Zn(II), Cu(I)or Cu(II) salts, and 1~4 molar equivalent of an organic base in organic solvent:

(b) mixing with the mixture of step (a) with 1.0 molar equivalent of \underline{a} reactant having a formular of of the structure

or of the structure

and maintaining the resulting reaction mixture at a temperature of between about 0-50°C for 1-20 hrs[.];

- (c) quenching by adding a proton source;
- (d) to give the desired obtaining the chiral compound.

Claim 16 (Currently amended): The \underline{A} compound of the structure or its enantiomer $\underline{having\ a\ formula\ of}$

wherein R1, R2 is an amino protecting group[,];

and R4 is an oxygen protecting group;

Z is NO2, CH3SO2, or CH3CH2SO3 mono or multisubstituted electron-

withdrawing group or electron-donating group;

and when Z is NO_2 at 4-postion of the phenyl, R^1 is $\bowtie \bowtie$, R^2 is $COCH_3$, R^4 is an only alkyl, substituted alkyl, benzyl, substituted benzyl, or trialkylsilyl;

and when Z is NO₂ at 4-postion of the phenyl, R¹, R² is CH₃, the ligand is only

(1R, 2R)-2-N,N-dimethylamino-1-(4- nitrophenyl)-3-O-R⁴-1-propanol[;]

and when Z is OCH3 at 4-postion of the phenyl, R¹, R² is CH3, R⁴ is an only alkyl,

substituted alkyl, benzyl, substituted benzyl; said substituted group is phenyl, naphthyl, halogen, NO₂, hydroxyl, C₁-C₁ hydroxyalkyl, C₁-C₄ alkyl, C₁-C₄ alkyl, C₁-C₅ alkoxy, or CN;

Claim 17 (Currently amended): The compound of claim 16 having a formula of postthe-structure or its enantiomer

Claim 18 (Currently amended): The compound of claim 16, of the structure having a formula of or its enantiomer

Claim 19 (Currently amended): The compound of claim 16, wherein R^1 and R^2 is an alkyl, substituted alkyl, benzyl, trialkylsilyl, or substituted benzyl, the substituted group ean-be being a phenyl, naphenyl, halo, nitro, hydroxy, C_1 - C_3 hydroxyalkyl, C_1 - C_4 alkyl, or C_1 - C_3 alkoxy[;], or R^1 , R^2 ean-be being -(CH₂)_nX(CH₂)_m-, where X ean-be being a CH₃, O, or NH;

n,m is an integer from 1 to 6;

 R^4 is <u>an</u> alkyl, substituted alkyl, benzyl, or substituted benzyl, the substituted group ean-be being a phenyl, naphenyl, halo, nitro, hydroxy, C_1 - C_3 hydroxy alkyl, alkyl, C_1 - C_3 alkoxy, or C_3 :

electronwithdrawing groupis halogen, <u>Z is</u> NO₂, CF3,CH₃SO₂, or CH₃CH₂SO_{2[,]}
PhCH₂OCO₂ or AcO₋;

 $electron-donating\ group\ is\ C_1-C_3\ alkoxy,OH,\ Me_2NCH_2CH_2O,\ Et_2NCH_2CH_2O,\ NH_3-C_1-C_4\ alkyli;$

and when Z is NO_2 at 4-postion of the phenyl, R^1 is N=0, R^2 is $COCH_3$, R^4 is only alkyl, substituted alkyl, benzyl, substituted benzyl, or trialkylsilyl;

and when Z is NO₂ at 4-postion of the phenyl, R^1 , R^2 is CH₃, the ligand is only (1R, 2R)-2-N,N-dimethyl-1-(4- nitrophenyl)-3-O- R^4 -1-propanol[;]

and when Z is OCH $_3$ at 4-postion of the phenyl, R^4 , R^2 is CH $_3$, R^4 is only alkyl, substituted alkyl, benzyl, substituted benzyl.

Claim 20 (Currently amended): The compound of according to claim 16, wherein R^1 and R^2 is a C_1 - C_{20} alkyl, C_1 - C_{20} substituted alkyl, trialkylsilyl, benzyl, or substituted benzyl, the substituted group of alkyl or benzyl ean-be being a phenyl, naphenyl, halo, nitro, hydroxy, C_1 - C_3 hydroxyalkyl, C_1 - C_4 alkyl, C_1 - C_3 alkoxy, or $CN[:]_4$ or R^1 , R^2 ean be being -(CH₂), $X(CH_2)_{m^2}$, where X can-be being CH_2 , O or NH;

n,m is an integer from 1 to 6;

R⁴ is <u>a</u> C₁~C₂₀ alkyl, C₁~C₂₀ substituted alkyl, benzyl, trialkylsilyl, or substituted benzyl, the substituted group ean be being <u>a</u> phenyl, naphenyl, halo, nitro, hydroxy,

C1~C3 hydroxyalkyl, C1~C4 alkyl, C1~C3 alkoxy or CN:

Z is H, F, Cl, Br, I, CH₃SO₂ OH, PhCH₂O, AeO, MeO, EtO, Me₂NCH₂CH₂O, Et. NCH₂CH₂O, PhCH₂OCO₂ + Bu, + Pr. NH₃ or NO₃:

and when Z is NO_2 at 4-postion of the phenyl, R^1 is $\bowtie \multimap$, R^2 is $COCH_3$, R^4 is only an alkyl, substituted alkyl, benzyl, substituted benzyl, or trialkylsilyloxy;

and when Z is NO₂ at 4-postion of the phenyl, R^1 , R^2 is CH₃, the ligand is only $(1R, 2R)-2-N,N-dimethyl-amino-1-(4-nitrophenyl)-3-O-R^4-propane-1-ol[;]$

and when Z is OCH₃ at 4 postion of the phenyl, R¹, R² is CH₃, R⁴ is only alkyl, substituted alkyl, benzyl, substituted benzyl; said substituted group is phenyl, naphthyl, halogen, NO₂, hydroxyl, C₁-C₂ hydroxyalkyl, C₁-C₄ alkyl, C₁-C₃ alkoxy₃ or CN₁.

Claim 21 (Currently amended): The compound of according to claim 16, wherein R^1 and R^2 is a C_1 - C_4 alkyl, tri-phenyl methyl, t-butyldimethylsilyl, benzyl unsubstituted or substituted with C_1 - C_4 alkyl $[:]_a$ para-methoxy benzyl $[:]_a$ para-nitrobenzyl $[:]_a$ para-chlorobenzyl $[:]_a$, 2. 4-dichlorobenzyl $[:]_a$, 2. 4-dimethoxybenzyl:

 R^4 is <u>a</u> C_1 ~ C_4 alkyl, tri-phenyl methyl, t-butyldimethylsilyl, benzyl unsubstituted or substituted with C_1 ~ C_4 alkyl[;], para-methoxy benzyl[;], para-nitrobenzyl[;], para-chlo-robenzyl[;], <u>2</u>, 4-dichlorobenzyl[;], <u>or</u> 2, 4-dimethoxybenzyl;

 $Z \text{ is H, F, Cl, Br, I, CH}_3SO_2 \text{ OH, PhCH}_2O, AcO, MeO, EtO, Me}_2NCH}_2CH}_2O, \\ Et_2NCH}_2CH}_2O, PhCH}_2OCO, +Bu, +Pr, NH}_3 \text{ or } NO}_3;$

and when Z is NO_2 at 4-postion of the phenyl, R^1 is $\bowtie =0$, R^2 is $COCH_3$, R^4 is only an alkyl, substituted alkyl, benzyl, substituted benzyl, or trialkylsilyl;

and when Z is NO_2 at 4-postion of the phenyl, R^1 , R^2 is CH_3 , the ligand is only (1R, 2R)-2-N,N-dimethyl-amino-1-(4-nitrophenyl)-3-O- R^4 -propane-1-ol[;] and when Z is OCH_3 at 4-postion of the phenyl, R^1 , R^2 is CH_3 , R^4 is only alkyl, substituted alkyl, benzyl, substituted-benzyl.